Application No.:

10/685,261

END920000181US2

Amendment Dated:
Reply to Office Action of:

March 25, 2005 January 25, 2005

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

- 1.-17. Cancelled
- 18. (Currently amended) A composite structure comprising, in order:
- a substrate;
- a polymeric layer including a first polymeric material

The structure of claim 17 in which the first polymeric material is a polyimide;

a layer consisting essentially of silicon-oxide; and

an added layer including a second polymeric material selected from the group consisting of polyimides, polyolefins, polyepoxides, polyurethanes, and polycarbonates.

- 19. (Original) The structure of claim 18 in which the second polymeric material is a polyimide.
- 20. (Previously Presented) The structure of claim 18 in which the substrate is an integrated circuit device and the second polymeric material is a polyepoxide.
- 21. (Original) The structure of claim 20 additionally comprising a chip carrier adjacent to the added layer.
- 22. (Currently Amended) The structure of claim-17_18 additionally comprising a layer of adhesion promoter between the silicon-oxide containing layer and the added layer.
- 23. (Original) The structure of claim 22 in which the adhesion promoter is selected from the group consisting of 3-amino-propyl-tri-ethoxy-silane, 3-glycidoxy-

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propyl-tri-methoxy-silane, N-(2-amino-ethyl)-3-amino-propyl-tri-ethoxy-silane, 3-amino-propyl-tri-methoxy-silane, N-(2-amino-ethyl)-3-amino-propyl-tri-methoxy-silane, 3-isocyanato-propyl-tri-ethoxy-silane, 10-amino-decyl-tri-methoxy-silane, 11-amino-undecyl-tri-methoxy-silane, n-propyl-tri-methoxy-silane, and phenyl-tri-methoxy-silane.

24.-35. Cancelled

- 36. (Previously Presented) The structure of claim 20 in which the added layer additionally comprises solid particles of a thermally conductive and electrically insulating material.
- 37. (Currently Amended) <u>The A-composite structure of claim 21-comprising, in order:</u>

a substrate;

a polymeric-layer-including-a-first-polymeric-material-selected from the group consisting of polyimides, polyelefins, polyepoxides, polyurethanes, and polycarbonates;

a silicon-oxide containing layer; and

<u>in which the an-added layer comprises comprising polyepoxide-and-solid particles</u> of a thermally conductive and electrically insulating material.

38-39. Canceled